

Photodegradation of sulfonamides in UV/ozone, UV/oxidant, and UV/ozone/oxidant systems: comparison in terms of mineralization efficiency and power consumption

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Received 28 August 2020; Accepted 15 December 2020

ABSTRACT

UV/O₃, UV/H₂O₂, UV/Na₂S₂O₈, UV/O₃/H₂O₂, and UV/O₃/Na₂S₂O₈ systems were used to mineralize sulfamethoxazole (SMX) and sulfathiazole (STZ). The effects of pH and salinity on sulfonamide mineralization were determined. The mineralization of sulfonamides exhibited pseudo-first-order kinetics. At pH 5, the pseudo-first-order rate constants (*k*) of SMX in the UV/O₃, UV/H₂O₂, UV/Na₂S₂O₈, UV/O₃/H₂O₂, and UV/O₃/Na₂S₂O₈ systems were 0.0193, 0.0011, 0.0022, 0.0172, and 0.0925 min⁻¹, respectively, and those of STZ were 0.0238, 0.0011, 0.0031, 0.0201, and 0.0536 min⁻¹, respectively. At pH 5, adding Na₂S₂O₈ to the UV/O₃ system promoted sulfonamide mineralization, whereas adding H₂O₂ to the UV/O₃ system inhibited it. At pH 9, adding Na₂S₂O₈ or H₂O₂ to the UV/O₃ system promoted sulfonamide mineralization. The highest efficiency of mineralization for both SMX and STZ was achieved using the UV/O₃/Na₂S₂O₈ system and the efficiency followed the order pH 5 > pH 7 > pH 9. In the UV/O₃/Na₂S₂O₈ system at pH 9, adding 0.62 mM salinity reduced the *k* value of SMX from 0.0224 to 0.0181 min⁻¹ and that of STZ from 0.0322 to 0.0233 min⁻¹. In the UV/O₃/H₂O₂ system at pH 9, adding 0.62 mM salinity reduced the *k* value of SMX from 0.0137 to 0.0065 min⁻¹ and that of STZ from 0.0159 to 0.0072 min⁻¹. The figure-of-merit electrical energy per order was used to estimate the electrical energy efficiencies of the systems. At pH 5, the UV/O₃/Na₂S₂O₈ system exhibited the highest energy efficiency for SMX mineralization whereas the UV/Na₂S₂O₈ system did so for STZ mineralization. The highest energy efficiency system varied with the parent compound.

Keywords: Sulfamethoxazole; Sulfathiazole; Ozone; Hydrogen peroxide; Persulfate; Mineralization

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1. Introduction

Advanced oxidation processes (AOPs) have emerged as promising alternatives for removing non-biodegradable compounds from wastewater due to their efficient generation of reactive oxygen species, such as sulfate radicals ($\text{SO}_4^{\bullet-}$), hydroxyl radicals (HO^{\bullet}), and superoxide radicals ($\text{O}_2^{\bullet-}$) [1]. In recent years, ultraviolet (UV)-based AOPs have been widely studied and used to degrade recalcitrant organic compounds. Klauson et al. [2] and Wang and Zhuan [3] indicated that AOPs had greater potential than conventional treatment processes to degrade and mineralize recalcitrant and toxic organic pollutants in water matrices.

Ozonation has excellent potential as a means of photodegradation for the following reasons; (i) it poses minimal danger to humans; (ii) it generates no sludge; (iii) all residual ozone can be decomposed easily into oxygen and water; (iv) it requires little space; and (v) the process is easily conducted [4]. Ozone has an oxidation potential of 2.07 V whereas HO^{\bullet} has an oxidation potential of 2.80 V, so direct oxidation is slower than radical oxidation. Ozonation under UV radiation removes organics more effectively than ozonation alone. The combined process is more effective because UV radiation accelerates the decomposition of ozone, yielding freer HO^{\bullet} , and therefore producing a higher ozonation rate. A disadvantage of ozonation alone for treating wastewater is the large amount of energy that is required; accordingly, any improvement that reduces the required reaction time would be welcomed.

UV/ H_2O_2 can generate HO^{\bullet} [5,6] and UV/ $\text{Na}_2\text{S}_2\text{O}_8$ can be activated to form HO^{\bullet} and $\text{SO}_4^{\bullet-}$ [6,7]. $\text{SO}_4^{\bullet-}$ has a lower reaction rate than HO^{\bullet} , but higher selectivity toward organic compounds and it is less influenced by impurities in water [7,8]. Zhang et al. [9] and Acosta-Rangel et al. [10] degraded sulfamethazine (SMZ) and sulfadiazine (SDZ) using UV, UV/ H_2O_2 , and UV/ $\text{K}_2\text{S}_2\text{O}_8$ systems, which have been proved to exhibit low selectivity toward various sulfonamides. Wang et al. [11] indicated that sulfamethoxazole (SMX) can be degraded effectively by HO^{\bullet} and $\text{SO}_4^{\bullet-}$. Gao et al. [12] used UV/ $\text{Na}_2\text{S}_2\text{O}_8$ to degrade sulfamethoxy-pyridazine (SMP) and found that rate of SMP degradation increased as the $\text{Na}_2\text{S}_2\text{O}_8$ dose was increased or the pH was decreased. The mineralization of sulfonamides was less effective than their degradation using either individual or simultaneous systems in ozone-based AOPs [13]. Zhou et al. [14] showed that sulfate radical-based AOPs had potential for removing sulfonamides from the environment. Combining various AOPs commonly produces interesting synergistic effects that can significantly reduce the reaction time. Accordingly, H_2O_2 or $\text{Na}_2\text{S}_2\text{O}_8$ was added to UV/ O_3 systems herein, to yield UV/ $\text{O}_3/\text{H}_2\text{O}_2$ and UV/ $\text{O}_3/\text{Na}_2\text{S}_2\text{O}_8$ systems that were used to mineralize pharmaceuticals. Antibiotic pharmaceuticals have been widely detected in the aquatic environment, raising increased concerns about the aquatic ecological system and potential risks to human health. Sulfonamide is one of the largest classes of antibiotics used globally. The eight currently used, common sulfonamides are sulfacetamide, sulfadiazine, sulfadoxine, sulfamethizole, SMX, sulfanilamide, sulfasalazine, and sulfisoxazole [15]. In tropical Asian waters, the most abundant antibiotic sulfonamide is SMX, followed by lincomycin

and sulfathiazole (STZ) [16]. Additionally, SMX, STZ, and SMZ are typical sulfonamides, which are widespread in aqueous environments and have aroused great concern in recent years [17]. Therefore, SMX and STZ were selected as the parent compounds in this study.

The photodegradation of aqueous organic pollutants is an electrical-energy-intensive process, and electrical energy typically represents a major fraction of its costs. Simple figures-of-merit that are based on electric energy consumption can therefore be very useful. Most relevant studies compare efficiencies using reaction rate constants. Few investigations have considered the effects of power consumption on photodegradation. Notably, the literature on simultaneously evaluating the photodegradation efficiency and power consumption of sulfonamide oxidation in various AOPs is scarce. Accordingly, the value of electrical energy per order of pollutant removal (EEO) is used herein to compare the energy efficiencies of tested systems. Identifying the optimal operational parameters is critical for the successful application of AOPs. The objectives of this study are as follows; (i) to compare the mineralization efficiencies of SMX and STZ in UV/ O_3 , UV/ H_2O_2 , UV/ $\text{Na}_2\text{S}_2\text{O}_8$, UV/ $\text{O}_3/\text{H}_2\text{O}_2$, and UV/ $\text{O}_3/\text{Na}_2\text{S}_2\text{O}_8$ systems; (ii) to determine the synergistic effects of adding H_2O_2 or $\text{Na}_2\text{S}_2\text{O}_8$ to UV/ O_3 at different pHs; (iii) to evaluate the effects of salinity on SMX and STZ mineralization; and (iv) to calculate the values of EEO and mineralization rates of all tested systems.

2. Materials and methods

2.1. Materials

SMX, STZ, sodium persulfate ($\text{Na}_2\text{S}_2\text{O}_8$), and phosphoric acid (H_3PO_4) were purchased from Sigma-Aldrich (USA). Table 1 presents the physiochemical properties of SMX and STZ. The hydrogen peroxide solution (H_2O_2 , 30% w/w) was obtained from Merck (USA). Salinity was provided by NaCl, which was obtained from Taiyen. The pH of the solution was controlled by adding HNO_3 and NaOH via an automatic titrator. All solutions were prepared using deionized water (D.I. water). All experimental chemicals were analytical grade and used as purchased.

2.2. Mineralization experiments

Ozone was produced using a corona discharge ozone generator (250 W, ozone solutions TG-20) with oxygen as the feed gas. Before the experiment, 1,500 mL of D.I. water was added to the reactor and then ozonized for 30 min, in which time a constant ozone concentration in an aqueous solution was reached. Then, 500 mL sulfonamide solution was added to the reactor. Ozone gas was continuously fed in with a constant flow rate of 3.353 L/min at 298 K. The residual ozone concentration in the solution was measured using the indigo colorimetric method (Method 4500) [18]. In this study potassium titanium(IV) oxalate spectrophotometric determination was used to obtain the concentration of residual hydrogen peroxide in the solution [19]. The initial concentrations of sulfonamide and NaCl were 0.08 and 0.62 mM, respectively, and the temperature was 298 K. Photodegradation experiments were conducted

in a 3 L glass reactor. The radius and height of the ozonation reactor were 14.5 and 23 cm, respectively. An 8 W UV lamp (254 nm, 1.12 W/m², Philips, China) was placed inside a quartz tube as a light source. The effects of H₂O₂ and Na₂S₂O₈ concentration on sulfonamide mineralization at pH 5 were evaluated. The effect of salinity on sulfonamide mineralization at pH 9 was determined. Twenty-milliliter aliquots were withdrawn from the reactor at pre-specified intervals. Na₂S₂O₈ and H₃PO₄ were utilized as the oxidant and the acidifier, respectively, in the total organic carbon (TOC) analyzer. The TOC values were measured by the thermal persulfate oxidation method. The decrease in TOC, measured using an O.I. 1010 TOC analyzer (O.I., College Station), revealed sulfonamide mineralization. The reported data are averages from triplicate samples.

3. Results and discussion

3.1. Effects of pH on sulfonamide mineralization

SMX and STZ have two pK_a values; therefore, they can exist in cationic, neutral, and anionic forms. Under environmental conditions, only the latter two forms are relevant. pH is an important factor that affects the photodegradation of sulfonamides; therefore, the effects of pH on sulfonamide mineralization in UV/O₃, UV/H₂O₂, UV/Na₂S₂O₈, UV/O₃/H₂O₂, and UV/O₃/Na₂S₂O₈ systems were investigated herein. Fig. 1 displays the results of SMX and STZ mineralization by UV photolysis, ozonation, persulfate, and hydrogen oxidation at pH 5. After 180 min of reaction, the SMX mineralization efficiencies by UV photolysis, O₃, persulfate, and hydrogen oxidation were 9%, 55%, 13%, and 16%, respectively (Fig. 1a); the STZ mineralization efficiencies were 7%, 68%, 13%, and 17%, respectively (Fig. 1b). Only O₃ significantly mineralized sulfonamide but the mineralization efficiency should be improved. Fig. 2 plots the SMX mineralization efficiency of various systems at different pHs. After

60 min of reaction, the SMX mineralization ratios in UV/O₃, UV/H₂O₂, UV/Na₂S₂O₈, UV/O₃/H₂O₂, and UV/O₃/Na₂S₂O₈ systems at pH 5 were 73%, 5%, 11%, 64%, and 96%, respectively; those at pH 7 were 64%, 6%, 17%, 68%, and 94%, respectively; and those at pH 9 were 54%, 6%, 14%, 60%, and 77%, respectively. Fig. 3 plots the STZ mineralization efficiency of various systems at different pHs. After a 60 min reaction, the STZ mineralization ratios in UV/O₃, UV/H₂O₂, UV/Na₂S₂O₈, UV/O₃/H₂O₂, and UV/O₃/Na₂S₂O₈ systems at pH 5 were 76%, 9%, 27%, 71%, and 95%, respectively; those at pH 7 were 73%, 7%, 15%, 66%, and 92%, respectively; and those at pH 9 were 50%, 14%, 28%, 65%, and 87%, respectively.

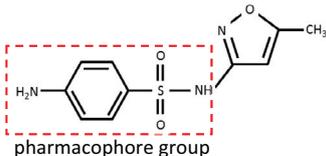
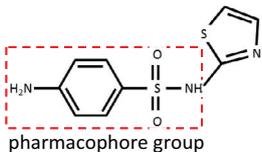
The mineralization follows pseudo-first-order kinetics as in Eq. (1):

$$\ln\left(\frac{C_t}{C_0}\right) = -kt \quad (1)$$

where C_t and C_0 (mg/L) are the concentrations of sulfonamides at reaction time t and the beginning of the reaction, respectively, and k (min⁻¹) is the pseudo-first-order rate constant of sulfonamide mineralization. Several researchers have indicated that the photodegradation of sulfonamides follows pseudo-first-order kinetics [6,12,21]. Table 2 presents the k values and correlation coefficients of sulfonamide mineralization in various oxidation systems. At pH 5, the k values of both SMX and STZ followed the order UV/O₃/Na₂S₂O₈ > UV/O₃ > UV/O₃/H₂O₂ > UV/Na₂S₂O₈ > UV/H₂O₂. In UV/O₃/Na₂S₂O₈, UV/O₃, and UV/O₃/H₂O₂ systems, the k values of SMX and STZ followed the order pH 5 > pH 7 > pH 9.

Ozone reacts with organics either by electrophilic attack or indirectly by a radical chain reaction, depending on the pH. Under alkaline conditions, ozone in solution rapidly decomposes to yield HO[•] and other radicals in solution (Eqs. (2)–(4)); under acidic conditions, ozone remains stable, and reacts directly with organic substrates [22]. Since

Table 1
Physiochemical properties of SMX and STZ

	SMX	STZ
Chemical formula	C ₁₀ H ₁₁ N ₃ O ₃ S	C ₉ H ₉ N ₃ O ₂ S ₂
Molecular weight (g mol ⁻¹)	253	255
CAS no.	723-46-6	72-14-0
logK _{ow}	0.89	0.05
Dissociation constants ^a	pK _{a1} = 1.6 and pK _{a2} = 5.7	pK _{a1} = 2.2 and pK _{a2} = 7.2
Melting point (K)	440	462
Solubility in water (mg L ⁻¹)	610 at 310 K	373 at 298 K
λ _{max} (nm)	266	283
Molecular structure		

^aBoreen et al. [20].

logK_{ow}: partition coefficient between water and octanol.

λ_{max}: maximum absorption wavelength.

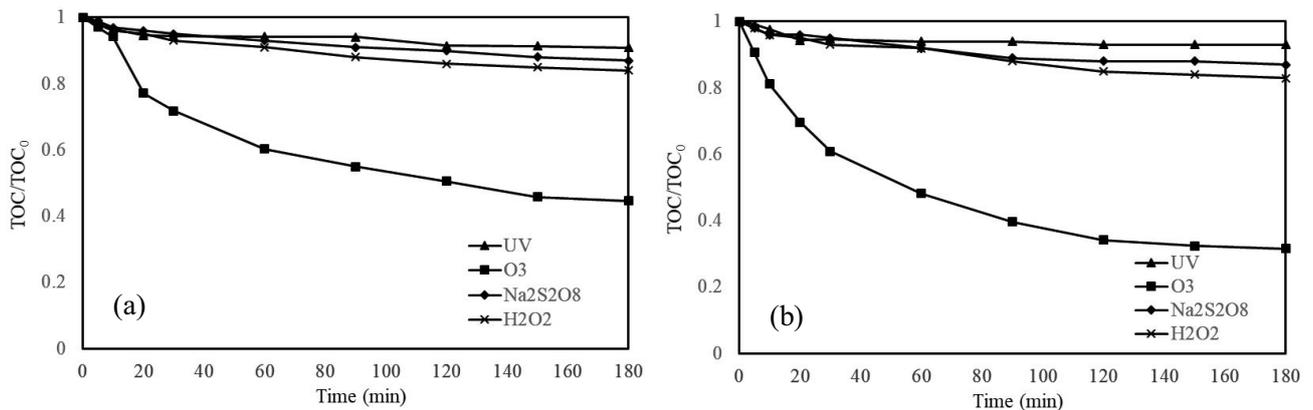


Fig. 1. SMX and STZ mineralization by UV photolysis, ozonation, persulfate, and hydrogen oxidation: (a) SMX and (b) STZ ([sulfonamide] = 0.08 mM; [oxidant] = 2.5 mM; pH 5; [O₃] = 0.14 mM).

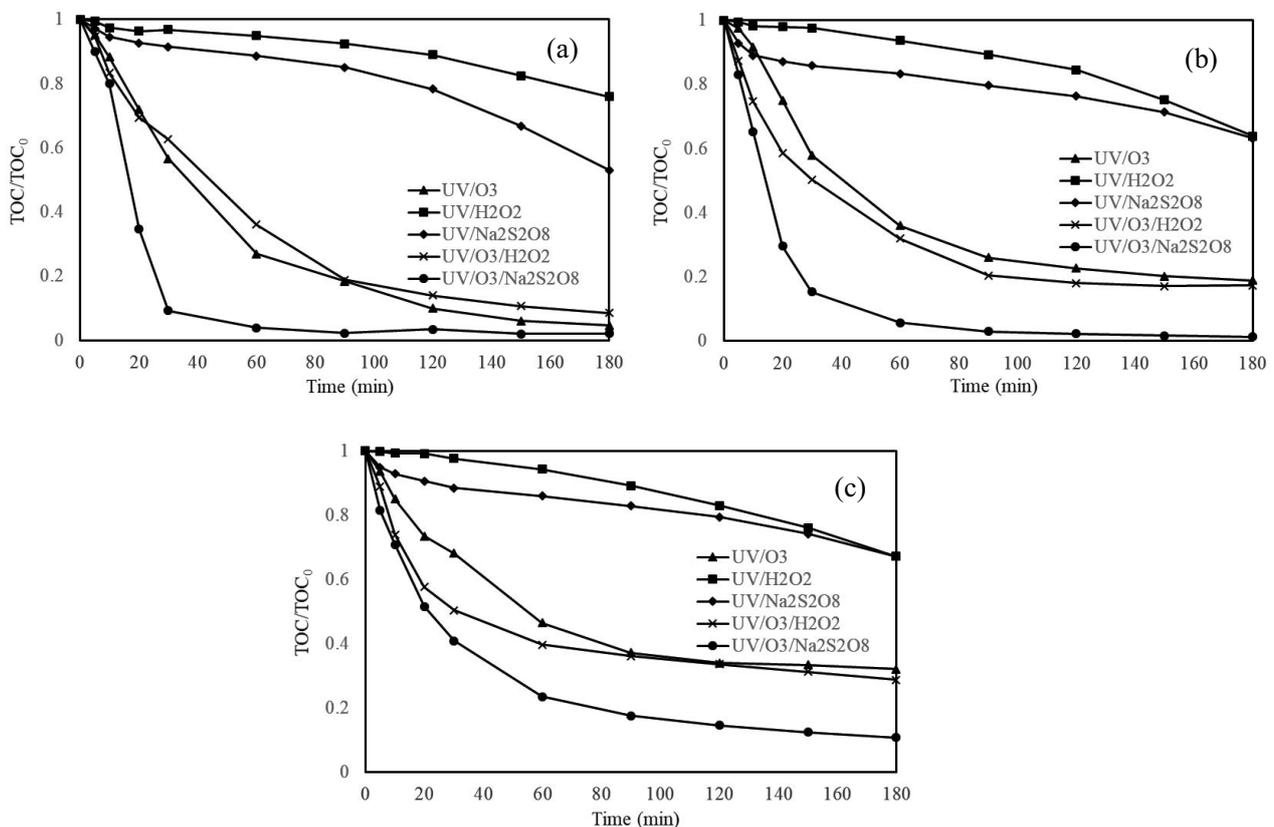


Fig. 2. Mineralization of SMX in different oxidation systems: (a) pH 5, (b) pH 7, and (c) pH 9 ([SMX] = 0.08 mM; [oxidant] = 2.5 mM; [O₃] = 0.14 mM).

the oxidation potential of HO[•] considerably exceeds that of ozone molecules, direct oxidation is slower than radical oxidation. Typically, at pH < 4, direct ozonation dominates; at pH 4–9, both direct and radical oxidation are important; and at pH > 9, the indirect pathway dominates [1]. UV radiation can decompose ozone in water, yielding HO[•] (Eq. (5)) [23]. The combined process is more effective than the process without UV because UV radiation promotes ozone decomposition, yielding additional HO[•],

increasing ozonation. Liu et al. [24] demonstrated that the removal of SMX by ozone was dominated by direct attack by molecular ozone rather than by free radicals; therefore, the removal rate of SMX increased as the pH decreased:



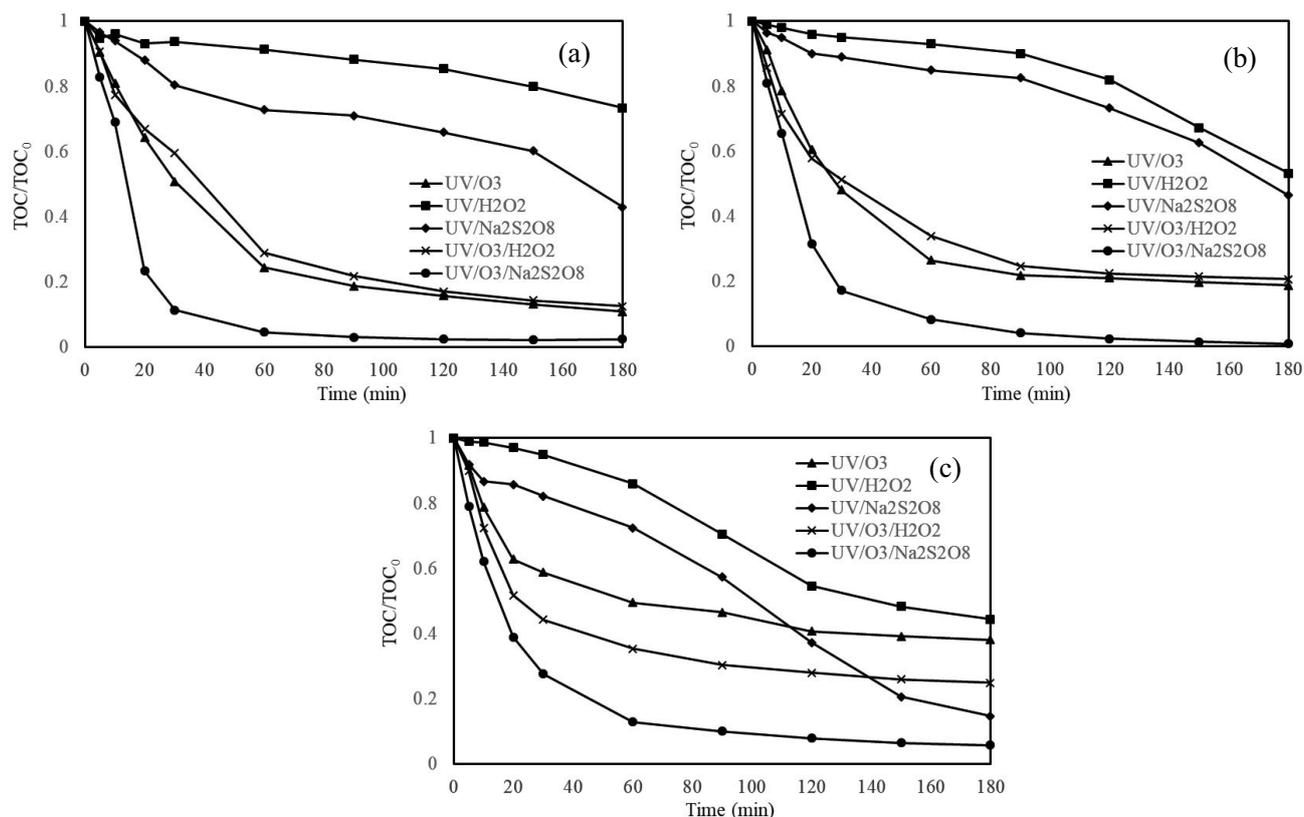


Fig. 3. Mineralization of STZ in different oxidation systems: (a) pH 5, (b) pH 7, and (c) pH 9 ([STZ] = 0.08 mM; [oxidant] = 2.5 mM; [O₃] = 0.14 mM).

Table 2

Pseudo-first-order reaction rate constants (k) and correlation coefficients (R^2) of sulfonamide mineralization in different oxidation systems ([sulfonamide] = 0.08 mM; [oxidant] = 2.5 mM; [O₃] = 0.14 mM)

SMX	pH 5		pH 7		pH 9	
	k (min ⁻¹)	R^2	k (min ⁻¹)	R^2	k (min ⁻¹)	R^2
UV/O ₃	0.0193	0.995	0.0160	0.983	0.0108 (0.0091) ^a	0.987 (0.991) ^a
UV/H ₂ O ₂	0.0011	0.920	0.0014	0.978	0.0013	0.969
UV/Na ₂ S ₂ O ₈	0.0022	0.920	0.0016	0.975	0.0015	0.981
UV/O ₃ /H ₂ O ₂	0.0172	0.992	0.0165	0.989	0.0137 (0.0065) ^a	0.897 (0.929) ^a
UV/O ₃ /Na ₂ S ₂ O ₈	0.0925	0.957	0.0692	0.996	0.0224 (0.0181) ^a	0.984 (0.985) ^a
STZ	k (min ⁻¹)	R^2	k (min ⁻¹)	R^2	k (min ⁻¹)	R^2
UV/O ₃	0.0238	0.999	0.0222	0.994	0.0103 (0.0090) ^a	0.856 (0.986) ^a
UV/H ₂ O ₂	0.0011	0.955	0.0014	0.934	0.0039	0.942
UV/Na ₂ S ₂ O ₈	0.0031	0.942	0.0026	0.937	0.0052	0.970
UV/O ₃ /H ₂ O ₂	0.0201	0.986	0.0159	0.970	0.0159 (0.0072) ^a	0.854 (0.944) ^a
UV/O ₃ /Na ₂ S ₂ O ₈	0.0536	0.924	0.0418	0.937	0.0322 (0.0233) ^a	0.975 (0.977) ^a

(^a): at 0.62 mM NaCl.

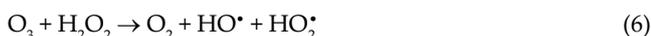


The efficiency of ozonation depends strongly on the rate of ozone decay. After the first 30 min of aeration of D.I. water with ozone, the dissolved ozone concentrations

at pH 5, pH 7, and pH 9 were 0.14, 0.09, and 0.04 mM, respectively. The residual ozone concentrations in solution followed the order pH 5 > pH 7 > pH 9, so the k values in the UV/O₃/Na₂S₂O₈, UV/O₃, and UV/O₃/H₂O₂ systems followed the same order as the residual ozone concentration. When the reaction at pH 5 began, molecular ozone might have primarily attacked sulfonamide molecules,

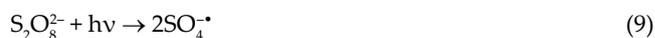
while at pH 9, the HO• attacked both sulfonamides and their degradation products. Klauson et al. [2] and Liu et al. [24] demonstrated that the removal of sulfonamides by ozone primarily involved direct attack by molecular ozone rather than by free radicals. Sulfonamides are aromatic compounds that are susceptible to electrophilic attack by ozone at low pH, at which the molecular ozone concentration is relatively high [25,26]. Urbano et al. [21] and Lin et al. [25] also reported that the degradation of sulfonamides by ozone decreased as pH increased.

Under alkaline conditions, H₂O₂ can react with O₃ in the UV/O₃/H₂O₂ system, yielding HO•, and hydroperoxyl radicals (HO₂•) (Eq. (6)) [27]. However, since Eq. (6) does not apply under acidic and neutral conditions, adding H₂O₂ to the UV/O₃ system did not increase the sulfonamide mineralization efficiency at pH 5 and 7. H₂O₂ scavenged HO• from the solution to form HO₂• (Eq. (7)). Eq. (8) describes the reaction in the UV/H₂O₂ system. Adding H₂O₂ to the UV/O₃ system at pH 5 or pH 7 suppressed the sulfonamide mineralization reactions (Table 2). In the UV/O₃/H₂O₂ system, the reactions are described by Eqs. (5)–(8), and the hybrid system at pH 9 provided a higher mineralization rate than the UV/O₃ and UV/H₂O₂ systems. The concentration of residual H₂O₂ in H₂O₂, UV/H₂O₂, and UV/O₃/H₂O₂ systems was measured herein. After 50 min of SMX mineralization at pH 5, the concentrations of residual H₂O₂ in H₂O₂, UV/H₂O₂, and UV/O₃/H₂O₂ system was 2.2, 1.7, and 0 mM, respectively (Fig. 4a); STZ mineralization yielded the same concentrations (Fig. 4b). UV decomposed H₂O₂ to HO• (Eq. (8)); H₂O₂ reacted with O₃ in the UV/O₃/H₂O₂ system, yielding HO•, and hydroperoxyl radicals (HO₂•) (Eq. (6)) [27]. Accordingly, the residual concentrations of H₂O₂ in the tested H₂O₂-base systems followed the order H₂O₂ > UV/H₂O₂ > UV/O₃/H₂O₂:



Gao et al. [12] suggested that persulfate ions undergo photolysis under UV irradiation, generating SO₄•⁻ (Eq. (9)). These SO₄•⁻ radicals then react with water molecules to

generate HO• (Eq. (10)). Li et al. [28] revealed that persulfate ions also reacted with water to yield SO₄•⁻ and superoxide radicals (O₂•⁻) (Eq. (11)). In the UV/O₃/Na₂S₂O₈ system, reactions that are described by Eqs. (5) and (9)–(11) proceeded simultaneously in solution. SO₄•⁻, HO•, and O₂•⁻ were the main oxidizing radicals in the UV/O₃/Na₂S₂O₈ system herein. Hu et al. [6] showed that SO₄•⁻ and HO• contributed to the degradation of iohexol in UV/S₂O₈²⁻ system. The *k* value of iohexol degradation in the UV/S₂O₈²⁻ system decreased as pH increased from 5 to 7, as did the *k* values of SMX and STZ herein. This result can be explained by the possibility that H⁺ accelerated persulfate decomposition to produce SO₄•⁻ and reduced the generation of HO• [6]. Under alkaline conditions (pH 7–9), the reactions between SO₄•⁻ and OH⁻ were accompanied by the generation of HO• (Eq. (10)); hence, the *k* value of sulfonamide mineralization in the UV/Na₂S₂O₈ system increased with pH from 7 to 9 (Table 2).



The lengths of the O–O bonds in H₂O₂ and S₂O₈²⁻ were 14.53 and 14.97 nm, respectively [29]. The molar extinction coefficient of S₂O₈²⁻, which was in the range of 190–320 nm, exceeded that of H₂O₂, suggesting that S₂O₈²⁻ is cleaved more easily than H₂O₂ and that the resulting SO₄•⁻ may be produced more readily than HO• [30]. The experimental results of this study are consistent with the fact that the photodegradation efficiencies of 4-fluorophenol [31], C.I. Reactive Black 5 [32], 2,4-dichlorophenol [30], Cu(II)-EDTA [5], and iohexol [6] follow the order UV/Na₂S₂O₈ > UV/H₂O₂.

To understand better the enhancement of sulfonamide mineralization in the UV/O₃/Na₂S₂O₈ system, the enhancement ratio (*α*) was introduced. When *α* = 0, the combined process is simply additive or cumulative; *α* > 1 indicates an increase in the removal rate in the measured system, and *α* < 1 indicates a reduction. The *α* values for SMX at pH 5, pH 7, and pH 9 were 4.3, 3.9, and 1.8, respectively, and those for STZ were 2.0, 1.7, and 2.1, respectively. The combination

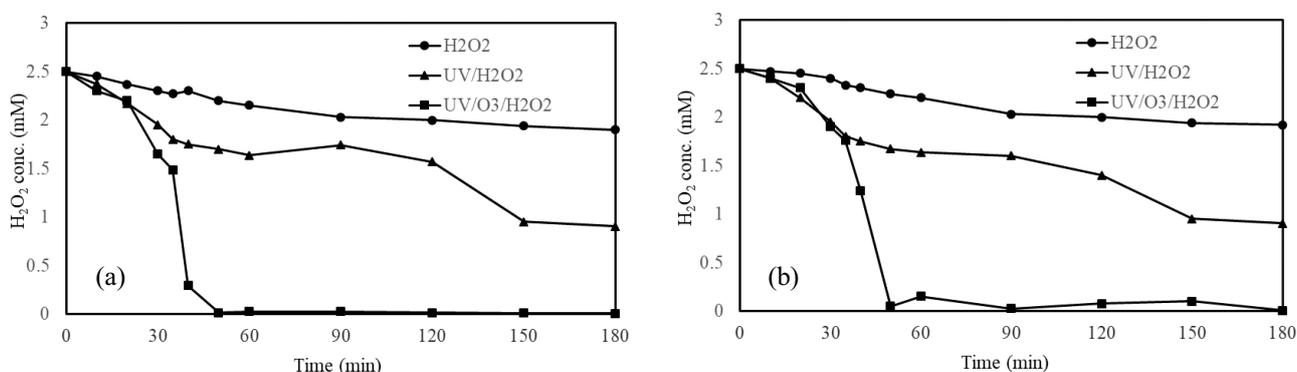


Fig. 4. Concentrations of residual H₂O₂ in H₂O₂, UV/H₂O₂, and UV/O₃/H₂O₂ systems: (a) SMX and (b) STZ ([sulfonamide] = 0.08 mM; pH 5; [H₂O₂] = 2.5 mM; [O₃] = 0.14 mM).

of Na₂S₂O₈ with UV/O₃ had significantly synergistic effects on sulfonamide mineralization. The UV/O₃/Na₂S₂O₈ system had the highest *k* values at all tested pHs and for both sulfonamides herein.

$$\alpha = [k(\text{UV/O}_3/\text{Na}_2\text{S}_2\text{O}_8)]/[k(\text{UV/O}_3) + k(\text{UV/Na}_2\text{S}_2\text{O}_8)] \quad (12)$$

Since the mineralization efficiency of the UV/O₃/H₂O₂ system did not always exceed that of the UV/O₃ system, the effects of H₂O₂ concentration on mineralization efficiency in the UV/O₃/H₂O₂ system were determined. Fig. 5 plots the effects of H₂O₂ concentration on sulfonamide mineralization efficiency in the UV/O₃/H₂O₂ system. After a 60 min reaction, the SMX mineralization ratios in the UV/O₃/H₂O₂ system with the addition of 0, 2.5, 5, and 10 mM H₂O₂ were 73%, 64%, 47%, and 45%, respectively, and those for STZ were 76%, 71%, 51%, and 45%, respectively. Generally, the photodegradation rate of organic compounds increases with H₂O₂ concentration up to a threshold, beyond which photodegradation efficiency declines as H₂O₂ increasingly scavenges HO• [32]. H₂O₂ at high concentration acts as a scavenger of HO•, generating HO₂•, which has a much lower oxidation capacity than HO• (Eq. (7)). As the H₂O₂ concentration in the UV/O₃/H₂O₂ system was increased from 2.5 to 10 mM, no improvement could be observed.

Accordingly, adding H₂O₂ to the UV/O₃ system had inhibitive effects at pH 5 and pH 7. Hence, the dose of H₂O₂ in the UV/O₃/H₂O₂ system must be carefully controlled.

Fig. 6 presents the effects of Na₂S₂O₈ concentration on sulfonamide mineralization efficiency in the UV/O₃/Na₂S₂O₈ system. After a 60 min reaction, the SMX mineralization percentages in the UV/O₃/Na₂S₂O₈ system with the addition of 0, 2.5, 5, and 10 mM Na₂S₂O₈ were 73%, 89%, 95%, and 97%, respectively, while the corresponding STZ mineralization percentages were 76%, 93%, 94%, and 95%, respectively. The mineralization of sulfonamide in the UV/O₃/Na₂S₂O₈ system increased with the concentration of added Na₂S₂O₈; however, adding more than 5 mM Na₂S₂O₈ in the UV/O₃ system resulted in an insignificant improvement in mineralization.

3.2. Effects of salinity on sulfonamide mineralization

The most abundant dissolved ions in seawater are sodium and chloride. Therefore, NaCl was added to the solutions as part of a study of the photocatalysis of sulfonamide mineralization at the same salinity levels as in seawater, to elucidate the effects of Na⁺ and Cl⁻ ions. Fig. 7 plots the effects of salinity on sulfonamide mineralization efficiency in UV/O₃, UV/O₃/H₂O₂, and UV/O₃/Na₂S₂O₈

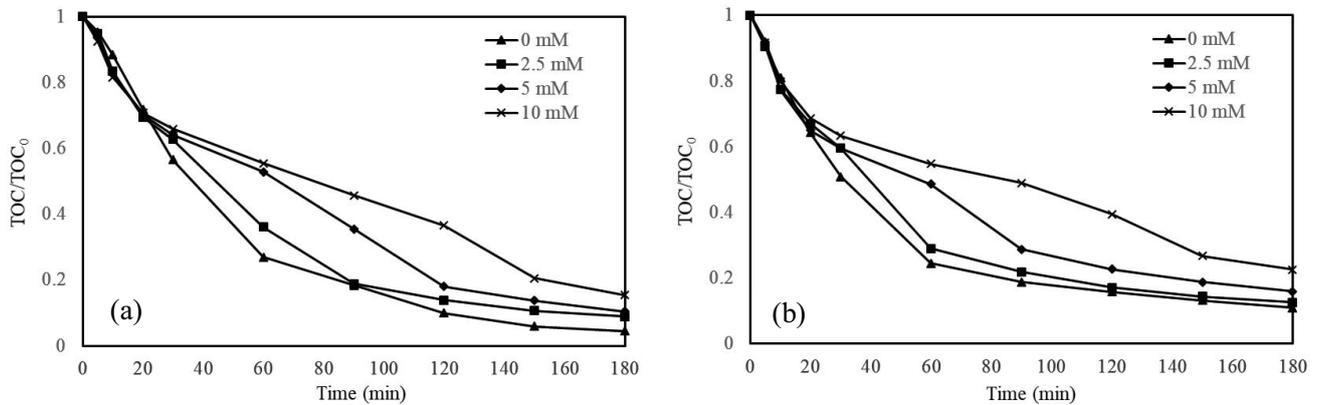


Fig. 5. Effects of H₂O₂ concentration on sulfonamide mineralization efficiency in UV/O₃/H₂O₂ system: (a) SMX and (b) STZ ([sulfonamide] = 0.08 mM; pH 5; [O₃] = 0.14 mM).

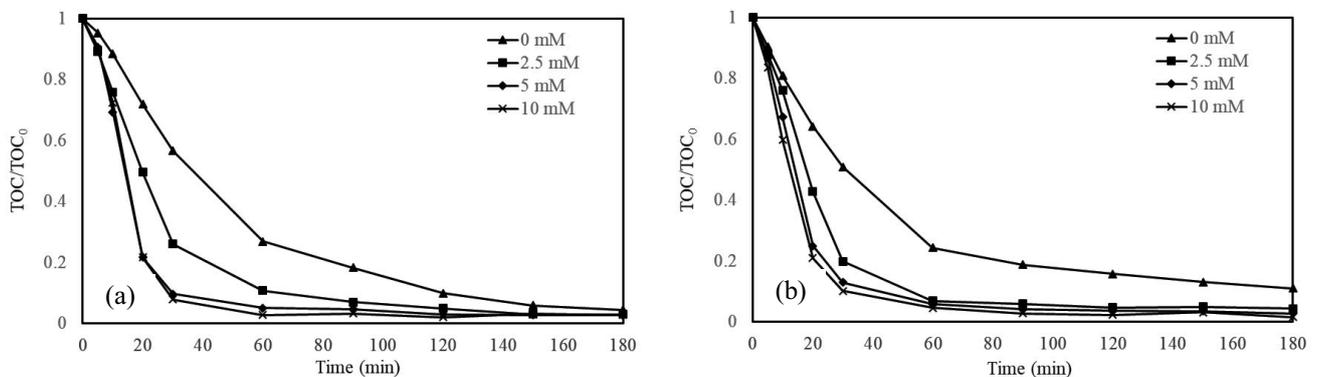


Fig. 6. Effects of Na₂S₂O₈ concentration on sulfonamide mineralization efficiency in UV/O₃/Na₂S₂O₈ system: (a) SMX and (b) STZ ([sulfonamide] = 0.08 mM; pH 5; [O₃] = 0.14 mM).

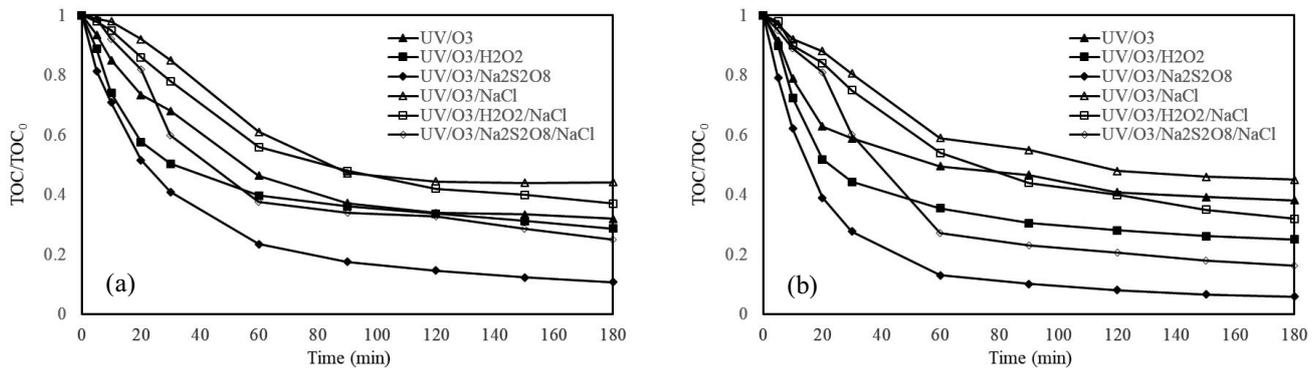


Fig. 7. Effects of salinity on sulfonamide mineralization efficiency in UV/O₃, UV/O₃/H₂O₂, and UV/O₃/Na₂S₂O₈ systems: (a) SMX and (b) STZ ([sulfonamide] = 0.08 mM; [oxidant] = 2.5 mM; [NaCl] = 0.08 mM; pH 9; [O₃] = 0.14 mM).

systems. After a 60 min reaction at pH 9, the SMX mineralization percentages in the UV/O₃/NaCl, UV/O₃/H₂O₂/NaCl, and UV/O₃/Na₂S₂O₈/NaCl systems were 39%, 44%, and 62%, respectively; the corresponding STZ mineralization percentages were 41%, 46%, and 73%, respectively. Adding NaCl reduced the *k* values of SMX and STZ in the UV/O₃, UV/O₃/H₂O₂, and UV/O₃/Na₂S₂O₈ systems. Inorganic salts influence ozonation as they are radical scavengers and affect the mass transfer rate [21]. The equations for the reaction of chloride ions with HO• (Eqs. (13) and (14)) [33] and SO₄^{•-} (Eqs. (15)) [6] are as follows. The oxidizing ability of Cl• is weaker than that of HO• and that of SO₄^{•-} [6,34], so the generation of Cl• reduced the rate of sulfonamide mineralization.



3.3. Analysis of electrical energy efficiency

The photodegradation of aqueous organic pollutant is an electrical-energy-intensive process, and electrical energy typically represents the largest part of the operating cost. Therefore, the energy efficiency must be evaluated. The figure-of-merit electrical energy per order (EEO) is appropriate for estimating the electrical energy efficiency [35]. It is a powerful scale-up parameter and measure of the rate of treatment in a fixed volume of contaminated water as a function of applied specific energy consumed [36]. The EEO value was used to compare the energy efficiencies of systems. For low pollutant concentrations, the EEO (kW h m⁻³ order⁻¹) value can be derived using Eq. (16).

$$\text{EEO} = \frac{(38.4 \times P)}{(V \times k)} \quad (16)$$

where *P* is the power (kW) of AOPs; *V* is the volume (L) of solution in the reactor; and *k* is the pseudo-first-order rate constant (min⁻¹) for mineralization [35,36]. A higher EEO value corresponds to a lower energy efficiency of the system. Table 3 summarizes the EEO value of various systems

Table 3

EEO value (kW h m⁻³ order⁻¹) of various systems under different pHs ([sulfonamide] = 0.08 mM; [oxidant] = 2.5 mM; [O₃] = 0.14 mM)

	pH 5	pH 7	pH 9
SMX	EEO	EEO	EEO
UV/O ₃	257	310	459
UV/H ₂ O ₂	140	110	118
UV/Na ₂ S ₂ O ₈	70	96	102
UV/O ₃ /H ₂ O ₂	288	300	362
UV/O ₃ /Na ₂ S ₂ O ₈	54	72	221
STZ	EEO	EEO	EEO
UV/O ₃	208	223	481
UV/H ₂ O ₂	140	110	39
UV/Na ₂ S ₂ O ₈	50	59	30
UV/O ₃ /H ₂ O ₂	246	312	312
UV/O ₃ /Na ₂ S ₂ O ₈	92	119	154

under different pHs. The EEO results at pH 5 revealed that the UV/O₃/Na₂S₂O₈ system consumed 79% and 56% less energy than the UV/O₃ system for SMX and STZ mineralization, respectively. For SMX, the UV/O₃/Na₂S₂O₈ system at pH 5 yielded the lowest EEO value; for STZ, the UV/Na₂S₂O₈ system at pH 9 did so. These results suggest that the optimal conditions (for both mineralization efficiency and energy consumption) varied with the sulfonamide, revealing that the development of a general mineralization method for a mixture of sulfonamides would be very difficult.

4. Conclusions

UV/O₃, UV/H₂O₂, UV/Na₂S₂O₈, UV/O₃/H₂O₂, and UV/O₃/Na₂S₂O₈ systems were used to mineralize SMX and STZ, and the mineralization rates and energy consumption efficiencies were compared. At pH 5, the *k* values of both SMX and STZ followed the order UV/O₃/Na₂S₂O₈ > UV/O₃ > UV/O₃/H₂O₂ > UV/Na₂S₂O₈ > UV/H₂O₂. For UV/O₃/Na₂S₂O₈, UV/O₃, and UV/O₃/H₂O₂ systems, the *k* values for both SMX and STZ followed the order pH 5 > pH 7 > pH 9. The combination of Na₂S₂O₈ with UV/O₃ had significantly synergistic

effects on the mineralization of sulfonamides. Salinity inhibited the mineralization of sulfonamides in UV/O₃, UV/O₃/H₂O₂, and UV/O₃/Na₂S₂O₈ systems owing to the scavenging of radicals by chloride ions. At pH 5, the most energy-efficient system for SMX mineralization was UV/O₃/Na₂S₂O₈ and that for STZ mineralization was UV/Na₂S₂O₈.

Acknowledgments

The authors would like to thank the Ministry of Science and Technology and National Kaohsiung University of Science and Technology, for financially supporting this research under Contract No. MOST 107-2221-E-992-001-MY2 and 109B01, respectively.

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